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APPLICATION NO.	FILING DATE	. FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
09/938,412	08/23/2001	Wan-Thai Hsu	UOM 0211 PUSP	9985
22045	7590 05/14/2003			
BROOKS & KUSHMAN			EXAMINER	
	CENTER 22ND FL D, MI 48075		KWOK, H	ELEN Č
			ART UNIT	PAPER NUMBER
			2856	
•			DATE MAILED: 05/14/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary

Application No. Applicant(s) 09/938,412

Hsu et al.

Examiner

H. Kwok

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	The MAILING DATE of this communication appears	on the cover sheet with the correspondence address			
Period for	• •				
THE M	PRTENED STATUTORY PERIOD FOR REPLY IS SET IAILING DATE OF THIS COMMUNICATION.				
mailing of the period of the p	date of this communication. Friod for reply specified above is less than thirty (30) days, a reply within t	and will expire SIX (6) MONTHS from the mailing date of this communication. he application to become ABANDONED (35 U.S.C. § 133).			
Status					
1) 💢 (Responsive to communication(s) filed on Mar 20, 2	2003 .			
2a) 💢	This action is FINAL . 2b) This act	tion is non-final.			
	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11; 453 O.G. 213.				
Dispositi	on of Claims				
4) 💢 (Claim(s) <u>1-24</u>	is/are pending in the application.			
4a	a) Of the above, claim(s)	is/are withdrawn from consideration.			
	Claim(s)				
6) 💢 (Claim(s) <u>1-24</u>	is/are rejected.			
	Claim(s)				
8) 🗆 (Claims	are subject to restriction and/or election requirement.			
Applicati	ion Papers				
9) 🗌 🗆	The specification is objected to by the Examiner.				
10) 🗆 🗀	The drawing(s) filed on is/are	a) \square accepted or b) \square objected to by the Examiner.			
	Applicant may not request that any objection to the d	rawing(s) be held in abeyance. See 37 CFR 1.85(a).			
11) 🗆 📑	The proposed drawing correction filed on	is: a) approved b) disapproved by the Examiner			
If approved, corrected drawings are required in reply to this Office action.					
12) 🗌 🗬	12) \square The oath or declaration is objected to by the Examiner.				
Priority u	inder 35 U.S.C. §§ 119 and 120				
13) Acknowledgement is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).					
a) All b) Some* c) None of:					
1.	1. Certified copies of the priority documents have been received.				
2.	. \square Certified copies of the priority documents hav	e been received in Application No			
	application from the International Bure				
*See	e the attached detailed Office action for a list of the	e certified copies not received.			
14) 🗌 🔏	Acknowledgement is made of a claim for domestic	priority under 35 U.S.C. § 119(e).			
	The translation of the foreign language provisiona				
15)∐ 4	Acknowledgement is made of a claim for domestic	priority under 35 U.S.C. §§ 120 and/or 121.			
Attachmen					
_	e of References Cited (PTO-892) e of Draftsperson's Patent Drewing Review (PTO-948)	4) Interview Summary (PTO-413) Paper No(s).			
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 5) Notice of Informal Patent Application (PTO-152) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s). 6) Other:					

DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the 1. basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- Claims 1-2, 4, 6-18 and 20-23 are rejected under 35 U.S.C. 102(b) as being anticipated by 2. Publication titled "Geometric Stress Compensation for Enhanced Thermal Stability in Micromechanical Resonators" (Hsu et al.).

With regards to claims 1-2, 4, 6-18, Hsu et al. discloses a micromechanical resonator comprising a semiconductor substrate, a single lateral flexural-mode resonator (the middle portion of the device, usually referred as the shuttle mass) made of polysilicon includes first and second ends; a temperature-compensating support structure (the inner and outer pair of folded beams with a truss support beam connecting the inner and outer pair of folded beams) is anchored by anchor lip to the substrate to support the resonator at the first and second ends above the substrate wherein the support structure includes a first support member (the inner pair of folded beams) and a second support member (the outer pair of folded beams and the truss support beam) for coupling the first support member to the resonator such that the first support member and the resonator have different effective lengths (See page 946, paragraph starting with "As

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shown, this device ..."); a drive electrode structure and a sense electrode structure made of plated metal are formed on the substrate. (As observed in Figures 2-4; pages 945-948, section I to IV).

With regards to claims 20-23, the claims are commensurate in scope with the above claims and are rejected for the same reasons as set forth above. Furthermore, the frequency versus temperature curve have peaks and valley and increases in dependance of the resonator. (See, Figures 1 and 9).

Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claims 3, 5, 19 and 24 are rejected under 35 U.S.C. 103(a) as being unpatentable over Publication titled "Geometric Stress Compensation for Enhanced Thermal Stability in Micromechanical Resonators" (Hsu et al.) in view of Publication titled "Micromachining Technologies for Miniaturized Communication Devices (Nguyen).

With regards to claims 3 and 5, Hsu et al. does not explicitly suggest a submicron lateral capacitive gap between the resonator and the electrodes. Nguyen discloses a resonator beam, as observed in Figure 9, a submicron gap between the resonator and the electrodes. It would have

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been obvious to a person of ordinary skill in the art at the time of invention to have readily recognize the advantages and desirability to implement the device of Hsu et al. to provide a submicron gap between the resonator and the electrodes as taught by Nguyen to reduce electrode series resistance. (See, page 29, last paragraph of Nguyen).

With regards to claim 19, it would have been obvious to an artisan to use the device as a temperature sensor since this is a mere design expedient to the manufacturer and since, as disclosed on page 948 of Hsu et al., the device can be used in watches or wireless transceivers, meaning that the device can be used in other preferred embodiments without departing from the scope of the invention.

With regards to claim 24, it would have been obvious to a person of ordinary skill in the art to have readily recognize the advantages and desirability of fabricating the first and second support members of the support structure wider than the resonator to prevent the support structure from vibrating during operation since one would normally realize in order to prevent the support structure from vibratory movement, one needs to make these support members more rigid and stronger by making its dimensions larger in width or length or by adding mass/weight to the support structure than the resonator so that when the resonator vibrates and/or bends at a certain direction (the x-direction or the y-direction), the support structure is not affected and will not vibrate and/or bend at that particular direction due to its larger dimensions and weight.

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Response to Amendment

5. Applicant's arguments with respect to claims 1-24 have been considered but are moot in view of the new ground(s) of rejection.

Conclusion

6. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL.** See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

7. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Helen Kwok whose telephone number is (703) 308-8149.

May 7, 2003

HELEN KWOK
PRIMARY EXAMINER